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AIChE officially launches AIChExchange at the Annual Meeting in San Francisco, November 13-18. This new electronic bulletin board is your ChemE connection to the "brave new world" of information management. It places information on AIChE programs, and open forums for the exchange of ideas as close as your keyboard. Eventually, it will also allow you to order books, register for meetings and courses, post meeting and program information, submit abstracts and proposals-to-present, exchange software...the possibilities are infinite!

If you're planning to be in San Francisco, stop by the demonstration area. Try out AIChExchange, give us your feedback, and take home a free disk that will enable you to access the bulletin board through a user-friendly graphic interface. Directions on how to access AIChExchange, will be available on-site, so you can spend more time exploring when you get home.

Can't make it to San Fran?...or just can't wait? Then feel free to "test-drive" AIChExchange right now. You can access with a modem connection by calling 212/705-8383 or via Internet using the telnet address bbserver.aiche.org. For more detailed instructions, call the AIChExpress FaxBack line at 212/705-8300 and request document number 6110.

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